



JPW AF/2814
RESPONSE UNDER 37 C.F.R. §1.116
EXPEDITE PROCEDURE
GROUP ART UNIT 2814 A

- 1 -

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Docket No.: FIS920030183US1

Dureseti CHIDAMBARRAO, *et al.*

Serial No.: 10/605,108

Group Art Unit: 2814

Confirmation No.: 2107

Filed: September 9, 2003

Examiner: PHAM, Long

For: **METHOD FOR REDUCING N+
DIFFUSION IN STRAINED SI
ON SI/GE SUBSTRATE**

Mail Stop: AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY UNDER 37 C.F.R. § 1.116

Sir:

In response to the **Final Office Action** mailed October 26, 2004 ("Office Action"), Applicants respectfully request entry of the accompanying Remarks and Amendments.

A Listing of the Claims is set forth on pages 2-7.

Remarks are set forth on pages 8-10.

Conclusions are set forth at page 11.

Applicants believe that no extensions of time are required at this time, but if extensions of time are necessary to prevent abandonment of this application, then such extensions of time are hereby petitioned under 37 C.F.R. §1.136(a), and any fees required therefor (including fees for net addition of claims) are hereby authorized to be charged to **Deposit Account No. 09-0458** (Fishkill). Please charge any underpayments and credit any overpayments to the same Deposit Account.